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(54) WAVEGUIDES FOR ENHANCED TOTAL INTERNAL REFLECTION FLUORESCENCE MICROSCOPY

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See application file for complete search history.

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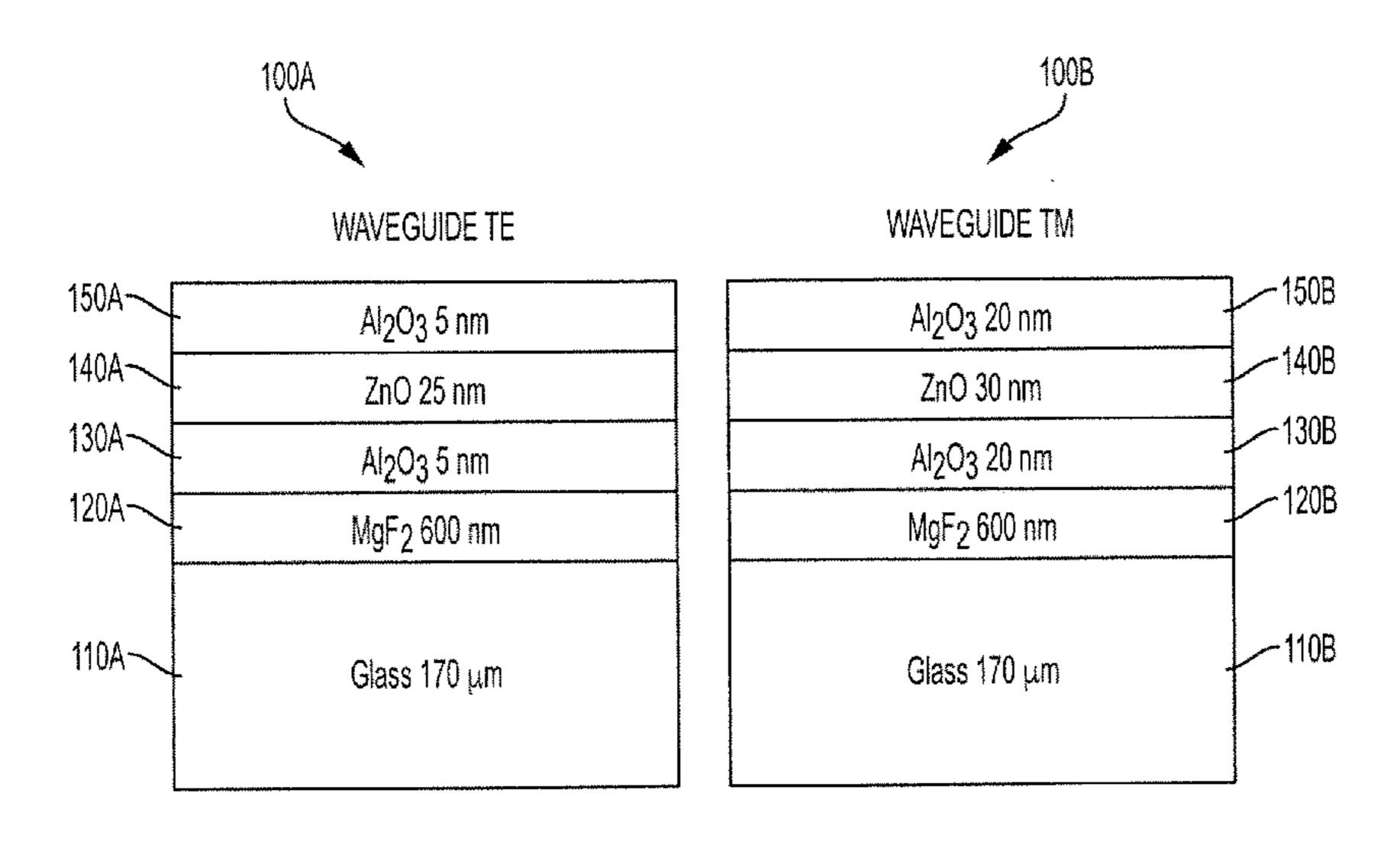
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(57) ABSTRACT

Evanescently-coupled planar waveguides for enhancing total internal reflection fluorescence microscopy are disclosed. The waveguides include multiple thin layers of one or more materials on a cover slip arranged resonantly enhance the optical field at the surface of the layer stack by evanescently coupling to a leaky guided mode.

12 Claims, 3 Drawing Sheets



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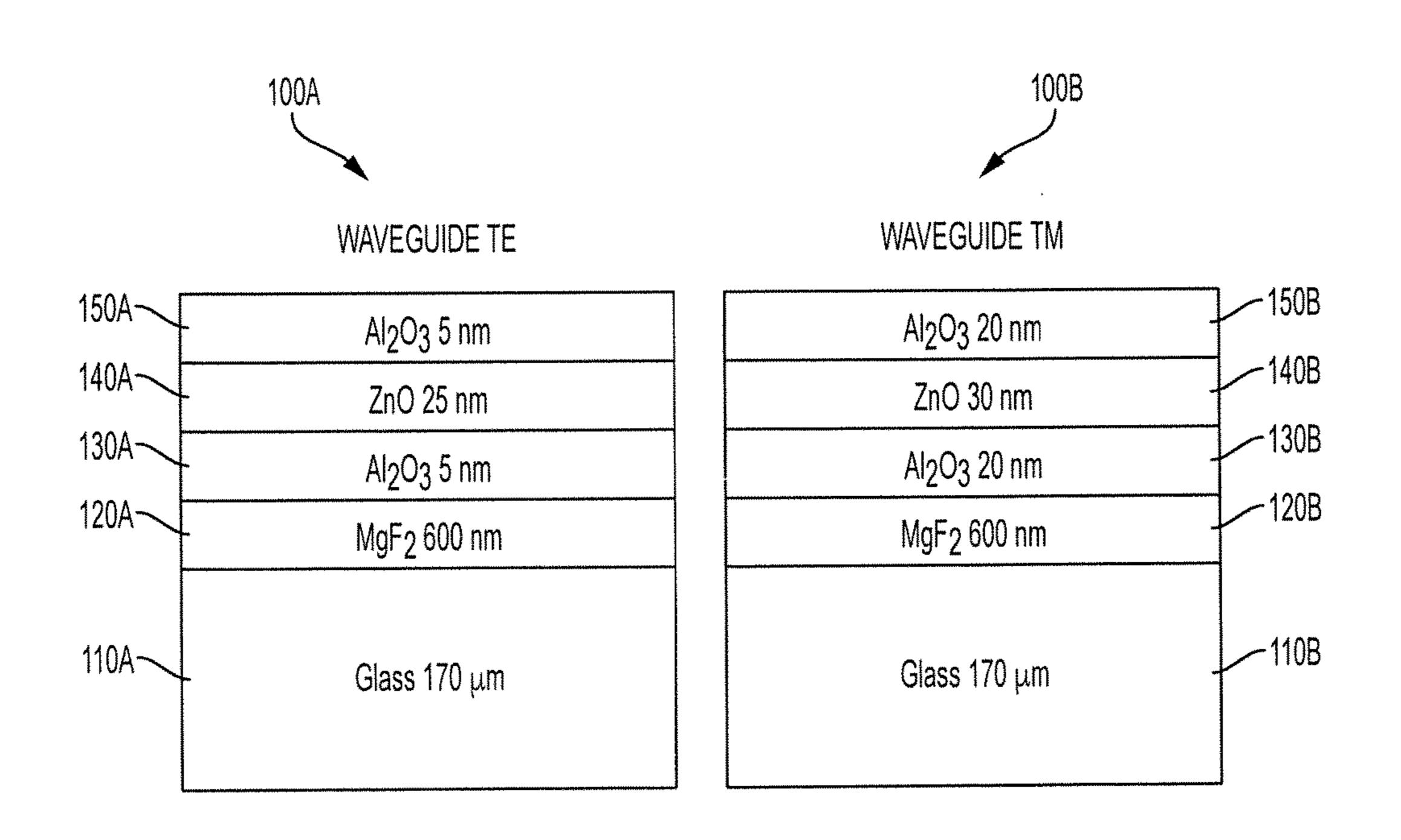
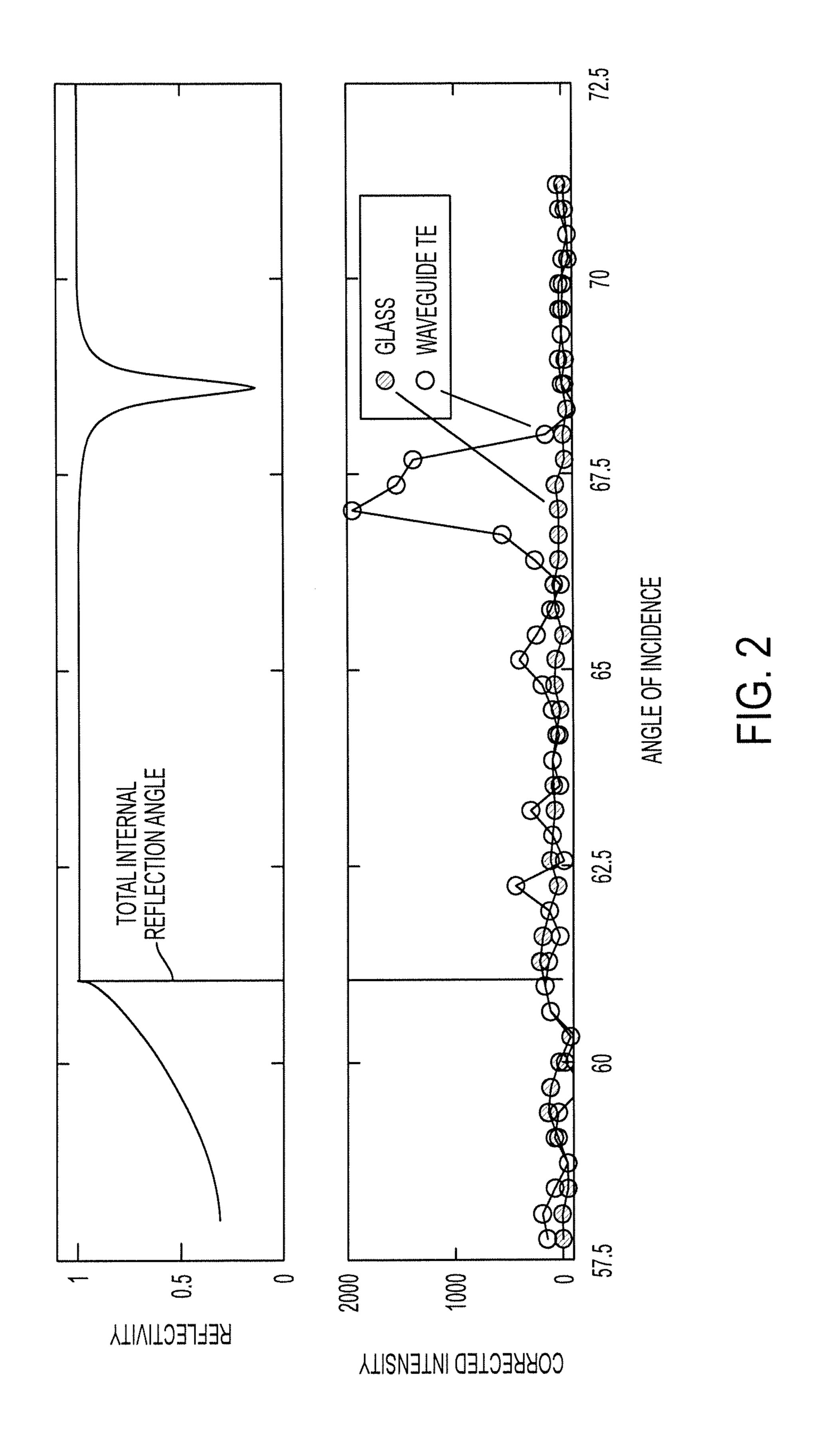
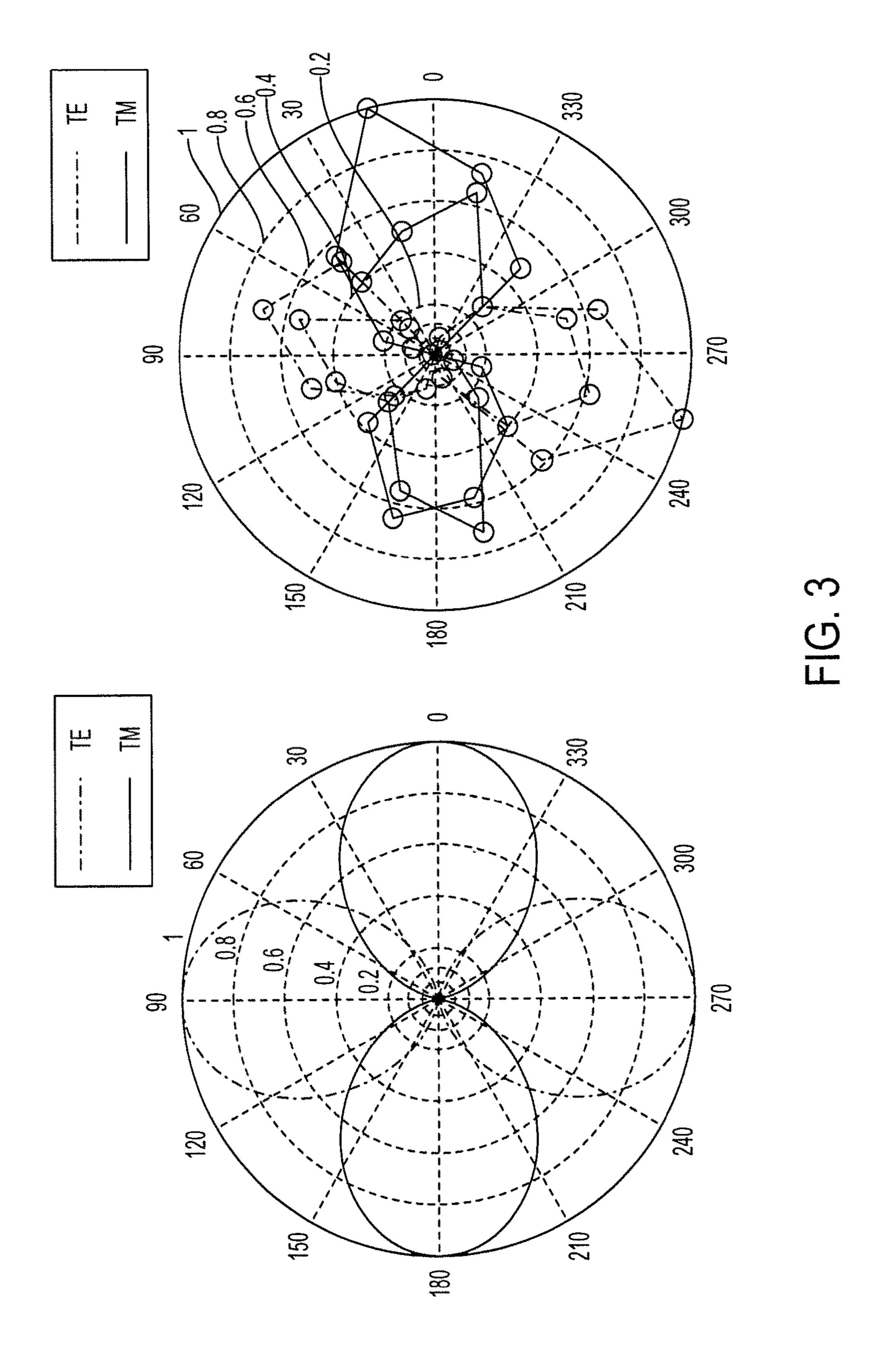


FIG. 1





WAVEGUIDES FOR ENHANCED TOTAL INTERNAL REFLECTION FLUORESCENCE MICROSCOPY

CROSS-REFERENCE TO RELATED APPLICATION

This application claims the benefit of U.S. Provisional Application No. 62/115,403 filed Feb. 12, 2015 the entire disclosure of which is hereby incorporated by reference herein.

STATEMENT REGARDING FEDERALLY SPONSORED RESEARCH

This invention was made with government support under 15 Grant No. GM010067, awarded by the National Institutes of Health. The Government has certain rights in the invention.

TECHNICAL FIELD

The present disclosure relates to total internal reflection fluorescence microscopy and in particular to evanescentlycoupled planar waveguides for enhancing such microscopy.

BACKGROUND

A total internal reflection fluorescence microscope (TIRFM) is a type of microscope that allows imaging of a thin region of a specimen which can include living cells. TIRFM exploits the unique properties of an induced eva- 30 nescent wave or field in a limited specimen region immediately adjacent to the interface between two media having different refractive indices. In practice, the most commonly utilized interface in the application of TIRFM is the contact area between a specimen and a glass cover slip.

The evanescent wave is generated only when the incident light is totally internally reflected at the glass-water interface. The evanescent electromagnetic field decays exponentially from the interface, and thus penetrates to a depth of only approximately 100 to 200 nm into the sample medium. 40 Thus, the TIRFM enables a selective visualization of surface regions such as the basal plasma membrane (which are about 7.5 nm thick) of cells.

Single-molecule TIRF microscopy has been enabled by technical advances in the fields of optics, materials science, and chemistry, and has been adopted as a standard technique in a number of fields. For example, the breakthrough of high quantum yield fluorophores allowed for high precision tracking of single molecular motors in vitro.

Limitations remain, however, in the number of photons 50 that reach the detector from a single fluorophore, ultimately restricting the temporal resolution of imaging experiments. Efforts to enhance TIRFM have been reported. See, e.g., Kim et al., "Thin-film-based sensitivity enhancement for total internal reflection fluorescence live-cell imaging", 55 Optics Letters, 2007:32(21):3062-3064 and Kim et al., "Feasibility study of enhanced total internal reflection fluorescence imaging using dielectric films" Multimodal Biomedical Imaging III, Azar et al. Ed., Proc. of SPIE Vol. 6850, 68500R-1 to 68500R-7 (2008). However, a continuing need 60 exists to enhance fluorescence microscopy.

SUMMARY OF THE DISCLOSURE

waveguide for use in total internal reflection fluorescence microscopy.

These and other advantages are satisfied, at least in part, by a cover slip comprising multiple thin layers of one or more dielectric materials on a glass substrate arranged in a planar fashion to couple to a discrete guided mode for resonant enhancement of an evanescent optical field at a surface of the multiple thin layers. For example, the cover slip can include: (i) a coupling layer directly adjacent a glass substrate having a refractive index n_c and a thickness more than about one-half an optical excitation wavelength; and (ii) one or more guide layers on the coupling layer having a refractive index n_{gi} that is more than a medium of a specimen, e.g., a medium of a specimen being imaged. Advantageously, the coupling layer refractive index n_c is less than the one or more guide layers refractive index n_{gi} and the guide layer thicknesses and guide layer refractive indices support a leaky guided mode.

Additional advantages of the present invention will become readily apparent to those skilled in this art from the following detailed description, wherein only the preferred ²⁰ embodiment of the invention is shown and described, simply by way of illustration of the best mode contemplated of carrying out the invention. As will be realized, the invention is capable of other and different embodiments, and its several details are capable of modifications in various obvi-²⁵ ous respects, all without departing from the invention. Accordingly, the drawings and description are to be regarded as illustrative in nature, and not as restrictive.

BRIEF DESCRIPTION OF THE DRAWINGS

Reference is made to the attached drawings, wherein elements having the same reference numeral designations represent similar elements throughout and wherein:

FIG. 1 illustrates examples of the design of the thin films 35 used in the waveguide.

FIG. 2 shows an example angle of incidence scan for waveguide TE used in TIRFM.

FIG. 3 is an example polarization scan using the waveguides.

DETAILED DESCRIPTION OF THE DISCLOSURE

As described in the Background section above, total internal reflection fluorescence microscopy (TIRFM) is limited in the number of photons that reach the detector from a single fluorophore, ultimately restricting the temporal resolution of imaging experiments. To address this problem, a novel dielectric waveguide was designed that can be used in existing commercial TIRF microscopes. A resonance effect along the waveguide lateral direction leads to enhancement of evanescent excitation. Use of the waveguide increases signal intensity from fluorescent probes by over an order of magnitude relative to a standard glass cover slip. The performance of the waveguide is further benchmarked using well-developed single-molecule kinesin motility assays. This technology has broad applications in the growing field of fluorescence microscopy, permitting much greater signals from the same molecular systems without the need for replacing existing microscopy setups.

In TIRFM, a laser beam passes through a high numerical aperture (N.A.) objective and undergoes total internal reflection when reflected from a high-refractive medium (e.g., glass) into a low refractive medium (e.g. cell/water). By An advantage of the present disclosure is a dielectric 65 using a high N.A. objective, the laser beam can leave the front optical plane of the objective at a supercritical angle to result in total internal reflection. This produces an electro3

magnetic evanescent wave which penetrates the cell membrane adjacent to the coverglass and excites fluorophores within an ultra thin optical section of about 100 nm, thereby reducing background noise from out-of-focus fluorescence.

In addition to TIRFM, the waveguide architecture is also useful for resonance sensing, in complete analogy to current commercially-available surface plasmon resonance sensors. The advantage of using a dielectric waveguide instead of a metal surface plasmon resonance is that, because the dielectric guide fundamentally enables lower loss than a surface plasmon, the sensitivity of the sensor can be improved, in principle by an arbitrary amount (though in practice limited by surface roughness of the dielectric layers). Surface plasmon resonance (SPR) sensors are widely used to detect everything from viruses to water contaminants. Biosensing Instrument Inc. of Arizona, USA produces commercial SRP thin in instruments.

In one aspect of the present disclosure, evanescent excitation of a TIRFM can be achieved by use of a cover slip, e.g., a glass substrate used to hold a specimen in a medium, 20 which includes multiple thin layers of one or more materials on the covers slip arranged in a planar fashion to create an evanescently-coupled waveguide. A distinguishing characteristic of this architecture is that (i) the refractive index, n_c , of the layer adjacent to the glass substrate, herein referred to 25 as the 'coupling layer' should be lower than the refractive indices of all subsequent layers, (ii) a thickness of the coupling layer should be greater than approximately onehalf of an optical excitation wavelength, (iii) a refractive index, n_{ei} , of the one or more layers deposited on top of the 30 coupling layer, herein referred to as the 'guide layer(s)' should exceed that of a medium of a specimen being imaged, i.e., the coverslip ambient (typically an aqueous medium with n~1.33), (iv) the uppermost guide layer is preferably physically stable (i.e. not dissolve) in the ambient solution 35 and (v) the combination of guide layer thicknesses and refractive indices must support a leaky guided mode.

For example, the multiple guide layers with high refractive index can have a refractive index of between 1.5 and 4.0. The coupling layer can have a low refractive index of 40 between 1.0 and 1.5. The optical excitation wavelength typically ranges between 300-700 nm, the coupling layer thickness typically exceeds 600 nm, and the collective thicknesses of the guide layers typically exceed 20 nm, for example.

In one aspect of the present disclosure, the high refractive index layer can include one or more dielectric materials such as TiO₂, ZnO, Al₂O₃, TeO₂, SiNx, conjugated polymers, chalcogenide glasses (and many others), and the low index materials can include MgF₂, CaF₂, PTFE/Teflon, nanop- 50 orous silicates/aerogels (and many others).

Advantageously, the guide layers have a refractive index of between 1.5 and 3 and a thickness range from 10% of the optical excitation wavelength to 10 times the optical excitation wavelength. Typical optical excitation wavelengths 55 range from about 300 nm to about 700 nm. Materials that are useful for the cover slip of the present disclosure include optical glass, such as, for example B270, BK7, SF10 or other high index glasses.

The significance of waveguides being composed entirely of dielectric materials is that they can be entirely transparent to the wavelengths of interest—that is, the materials have little to no absorption at either the excitation or emission wavelengths of interest, between a range of 300 nm and 700 nm. In an embodiment of the present disclosure the guide 65 layers have an absorption coefficient of less than 1 cm⁻¹ at wavelengths exceeding 400 nm. This is a fundamental

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difference relative to surface plasmon-based strategies involving metals, which are inherently absorptive and perform poorly at all wavelengths of interest. The degree to which a resonant structure (such as a waveguide or surface plasmon polariton (SPP)) enhances the optical field is inversely linked to its absorption. Consequently, pure dielectric waveguides can reach higher optical field enhancements than metal-based surface plasmon polariton modes, and thereby enable a large signal increase for TIRFM measurements

As explained above, the waveguides could also be useful as analogs of SPR-based sensors, with the advantage of improving sensitivity. In this case, the basic architecture remains the same. Such an architecture includes a transparent substrate (macroscopically thick ~1 mm), followed by a thin intermediate layer with low refractive index (less than that of the substrate, typically ranging from n of from about 1.0 to 1.4) and thickness on the order of the emission wavelength, and then subsequently by one or more layers with high refractive index (greater than that of the substrate, typically ranging from n of about 1.6 to about 4.0) and a collective thickness that is again on the order of the optical excitation wavelength. The primary difference for resonance sensing applications is that the top-most layer might be functionalized with, for example, some type of anti-body or agent to bind the target analyte (e.g. a virus) to the film surface.

An example of such a device includes multiple thin layers of dielectric materials deposited in a planar fashion on top of a glass cover slip. The finely tuned thicknesses and indices of refraction of these layers lead to reflection as a function of the incident laser wavelength, angle of incidence, and polarization. Here the layers are designed as so to best amplify the energy passed into the evanescent wave at a designed resonance angle. This leads to better excitation of fluorophores in TIRFM. Additionally, the single evanescent wave that can be made by coupling into the waveguide has physical parameters that are specifically optimized for TIRFM on biological samples. Whereas in conventional TIRFM the initial intensity and penetration depth of the evanescent wave ends up being limited by the numerical aperture of the objective. However, using the waveguide of the present disclosure the optimal evanescent wave can be made by any objective that can reach the coupling angle. The 45 coupling angle is specifically designed to be accessible by many objectives, eliminating the need for expensive, very high numerical aperture objectives in TIRFM.

FIG. 1 illustrates examples of the design of the thin films used in the waveguide of the present disclosure. Two versions of the waveguide are made and tested; one that coupled only transverse electric (TE)-polarized light (100A), and one that coupled only transverse magnetic (TM)-polarized light (100B). These waveguides were made by first thermally evaporating a layer of MgF₂ (120A, 120B) over a glass substrate (110A, 110B), followed by plasma-enhanced atomic layer deposition of Al₂O₃ (130A, 130B), ZnO (140A, **140**B), and Al₂O₃ (**150**A, **150**B). The top tri-layer (alumina/ ZnO/alumina) is not a necessary combination for optical performance, it could equally well include an all alumina or ZnO layer instead, or any other material with refractive index greater than the MgF₂ coupling layer. An advantage of this combination, however, is that it can protect the ZnO from dissolving certain aqueous bio-solutions that can be imaged. For these embodiments, the thicknesses of the layers for the waveguide TE (100A) were 5 nm for Al₂O₃ (150A), 25 nm for ZnO (140A), 5 nm for Al₂O₃ (130A) and 600 nm for the MgF₂ coupling layer (120A). The thicknesses

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of the layers for the waveguide TM (100B) were 20 nm for Al_2O_3 (150B), 30 nm for ZnO (140B), 20 nm for Al_2O_3 (130B) and 600 nm for the MgF_2 coupling layer (120B). For both waveguides, the glass substrate had a thickness of 170 microns.

FIG. 2 shows an example angle of incidence scan for waveguide TE used in TIRFM. The intensity of a fluorescent microsphere is measured as a function of the input light angle of incidence with TE polarization. The top graph shows the resonance angle of the waveguide according to a 10 theoretical model. The bottom graph shows experimental data for the intensity of a fluorescent microsphere as a function of incident light angle. For Regular TIRFM, shown in gray, a slight increase is seen at the critical angle (denoted). For the waveguide (black), a large increase in signal 15 is seen at the coupling angle. The slight discrepancy between the theoretical and experimental resonance angle may be to either error in the measurement of incident angle, or in experimental error in film deposition. This data show that an enhancement in total signal of well over an order of mag- 20 nitude is feasible with the waveguides.

FIG. 3 is an example polarization scan using the waveguides. The left plot shows the theoretical transmission of light through either the TE (gray) or TM (black) waveguide as a function of input light linear polarization angle. The 25 right plot shows the normalized measured intensity (radial axis) of a fluorescent microsphere as a function of incident linear polarization angle. The TE waveguide only couples at TE polarization, and the TM waveguide only couples at TM polarization. Both waveguides transmit no light at the crosspolarization, leading to zero signal from the microspheres. This test benchmarks the successful coupling of the waveguides.

TIRFM is currently limited by the high numerical aperture that must be used. The initial intensity and penetration 35 depth of the evanescent wave used for excitation are both functions of the incident wavelength and angle of incidence, as well as the index of refraction of the glass slide and the biological material (usually close to water, n=1.33). Simply increasing the laser power leads to higher intensity evanes- 40 cent wave, but also increases the intensity of light >100 nm away from the coverslip, defeating the purpose of the technique. Using a higher index of refraction cover slip can lead to an improved evanescent wave, but requires a higher numerical aperture objective, as the NA must be very close 45 to the cover slip index in order to transmit light. Thus, to improve TIRFM, you must buy as high an NA objective as possible. High performance optics of these types can cost more than \$10,000.

EXAMPLES

The following examples are intended to further illustrate certain preferred embodiments of the invention and are not limiting in nature. Those skilled in the art will recognize, or 55 be able to ascertain, using no more than routine experimentation, numerous equivalents to the specific substances and procedures described herein.

The coverslip waveguides were fabricated by first thermally evaporating a layer of MgF₂ on to a cover slip, followed by atomic layer deposition of Al₂O₃ and ZnO.

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Other structures were prepared as described above in the detailed Description of the Disclosure.

Only the preferred embodiment of the present invention and examples of its versatility are shown and described in the present disclosure. It is to be understood that the present invention is capable of use in various other combinations and environments and is capable of changes or modifications within the scope of the inventive concept as expressed herein. Thus, for example, those skilled in the art will recognize, or be able to ascertain, using no more than routine experimentation, numerous equivalents to the specific substances, procedures and arrangements described herein. Such equivalents are considered to be within the scope of this invention, and are covered by the following claims.

What is claimed is:

- 1. A cover slip for resonant enhancement of an evanescent optical field, comprising a cover slip having:
 - (i) a coupling layer directly adjacent a glass substrate having a refractive index n_c, and a thickness more than about one-half an optical excitation wavelength; and (ii) one or more guide layers on the coupling layer having a refractive index n_{gi} that is more than a medium of a specimen; wherein n_c is less than refractive indices of any layer subsequent to a coupling layer; and wherein a guide layer thickness and guide layer refractive index support a leaky guided mode.
- 2. The cover slip of claim 1, wherein each of the one or more guide layers has a refractive index between 1.5 and 4.0.
- 3. The cover slip claim 1, wherein the coupling layer has a refractive index between 1.0 and 1.5.
- 4. The cover slip of claim 3, wherein the coupling layer includes one or more of MgF₂, CaF₂, PTFE/Teflon, or nanoporous silicates/aerogels.
- 5. The cover slip of claim 1, wherein the collective thickness of the one or more guide layers ranges from 0.1 times the optical excitation wavelength to 10 times the optical excitation wavelength.
- 6. The cover slip of claim 1, wherein the one or more guide layers include one or more of TiO₂, ZnO, Al₂O₃, TeO₂, SiN_X, conjugated polymers, or chalcogenide glasses.
- 7. The cover slip of claim 1, further comprising a specimen thereon wherein the specimen includes a fluorophore.
- 8. The cover slip of claim 1, wherein the one or more guide layers include one or more of ZnO and/or Al;₂O₃ and the coupling layer includes one or more layers of MgF₂.
- 9. The cover slip of claim 1, wherein the one or more guide layers include a layer of ZnO between two layers of Al₂O₃ and the coupling layer includes MgF₂.
- 10. The cover slip of claim 1, wherein the optical excitation wavelength ranges between 300-700 nm.
- 11. The cover slip of claim 1, wherein the one or more guide layers on the coupling layer have n_{gi} that is more than about 1.33.
- 12. The cover slip of claim 1, wherein the thickness of the coupling layer directly adjacent the glass substrate is 600 nm or more.

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